



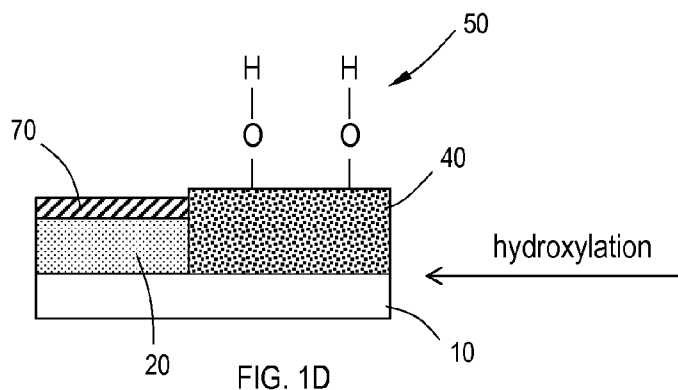
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(54) **Title:** SELECTIVE DEPOSITION WITH ALCOHOL SELECTIVE REDUCTION AND PROTECTION



(57) **Abstract:** Methods of selectively depositing a metal selectively onto a metal surface relative to a dielectric surface. Methods include reducing a metal oxide surface to a metal surface and protecting a dielectric surface to minimize deposition thereon.